

Supplementary Information for

Predicted high thermoelectric performance in two-dimensional Indium Telluride and its dependence against strain

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Table S1. Structural parameters for 2D MX (M =Ga, In and X =S, Se, Te) monolayers, including lattice constant (a), bond length (d_{MM} and d_{MX}), layer thickness (δ) and bond angle (θ_1 and θ_2), as depicted in Fig. 1.

	$a/\text{\AA}$	$d_{MM}/\text{\AA}$	$d_{MX}/\text{\AA}$	$\delta/\text{\AA}$	θ_1/deg	θ_2/deg
GaS	3.629	2.472	2.360	4.645	117.4	100.5
GaSe	3.813	2.469	2.496	4.820	118.1	99.60
GaTe	4.130	2.467	2.704	5.019	118.2	99.56
InS	3.924	2.825	2.553	5.179	117.5	100.4
InSe	4.086	2.822	2.682	5.371	118.4	99.26
InTe	4.387	2.814	2.884	5.571	118.6	99.04

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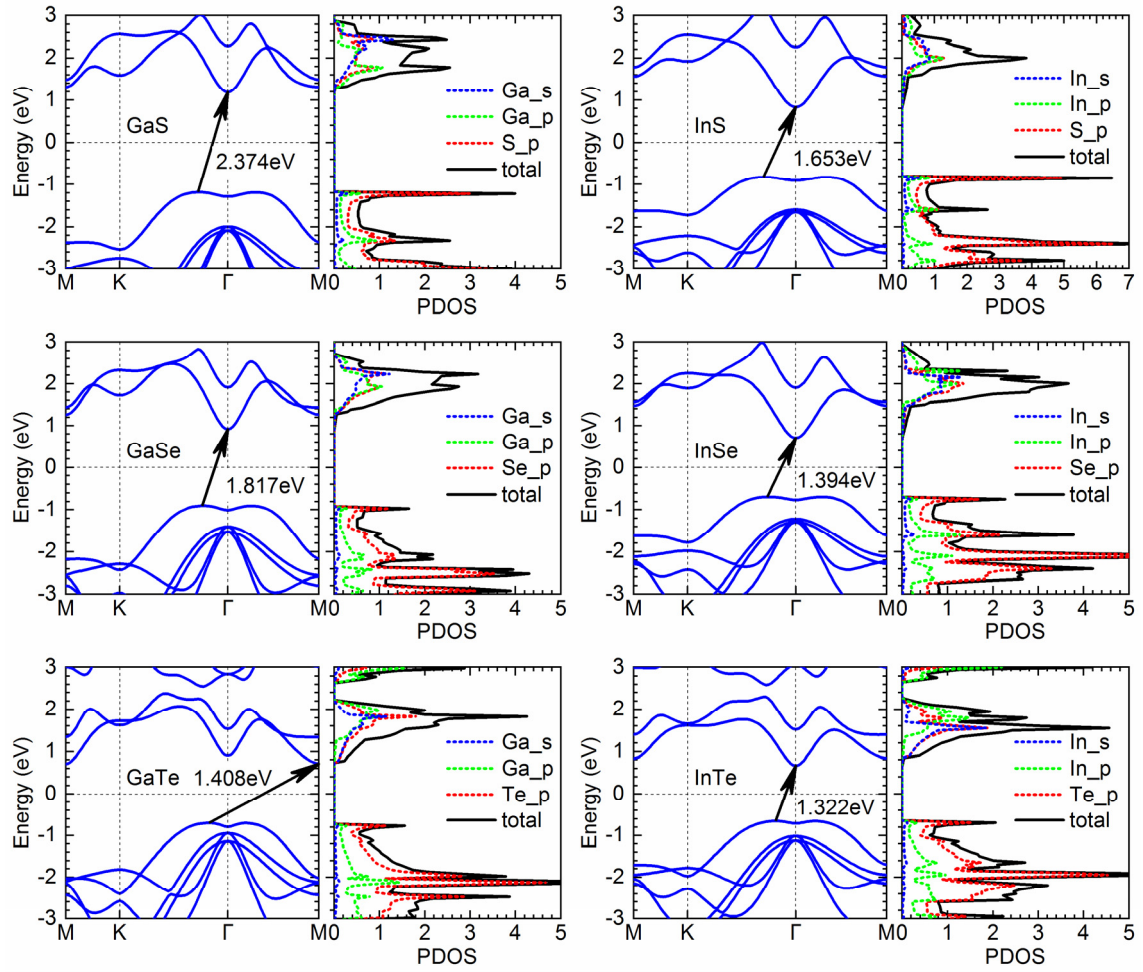


Figure S1. Electronic band structures and projected density of states (DOS) for MX ($M=\text{Ga, In}$ and $X=\text{S, Se, Te}$) monolayers.

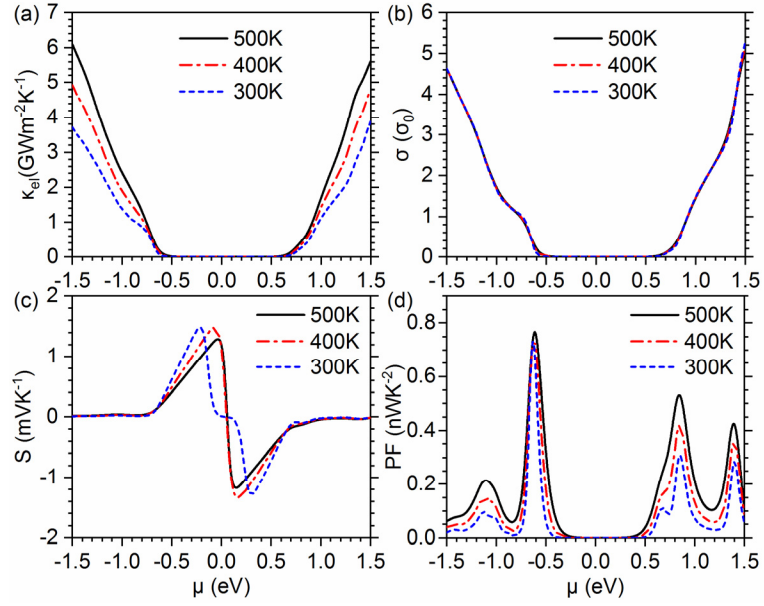


Figure S2. (a) Electronic thermal conductance κ_{el} , (b) electronic conductance σ , (c) Seebeck coefficient S and (d) power factor PF as functions of chemical potential μ for InTe monolayers at different temperatures.

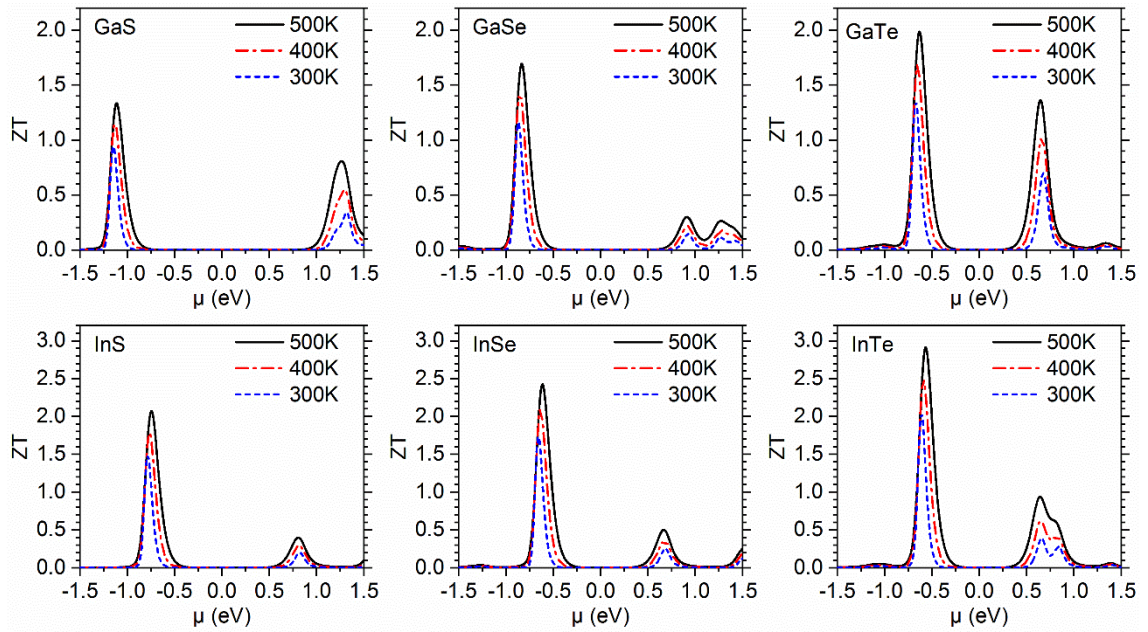


Figure S3. ZT value for MX ($M=\text{Ga, In}$ and $X=\text{S, Se, Te}$) monolayers as a function of chemical potential μ at different temperatures.

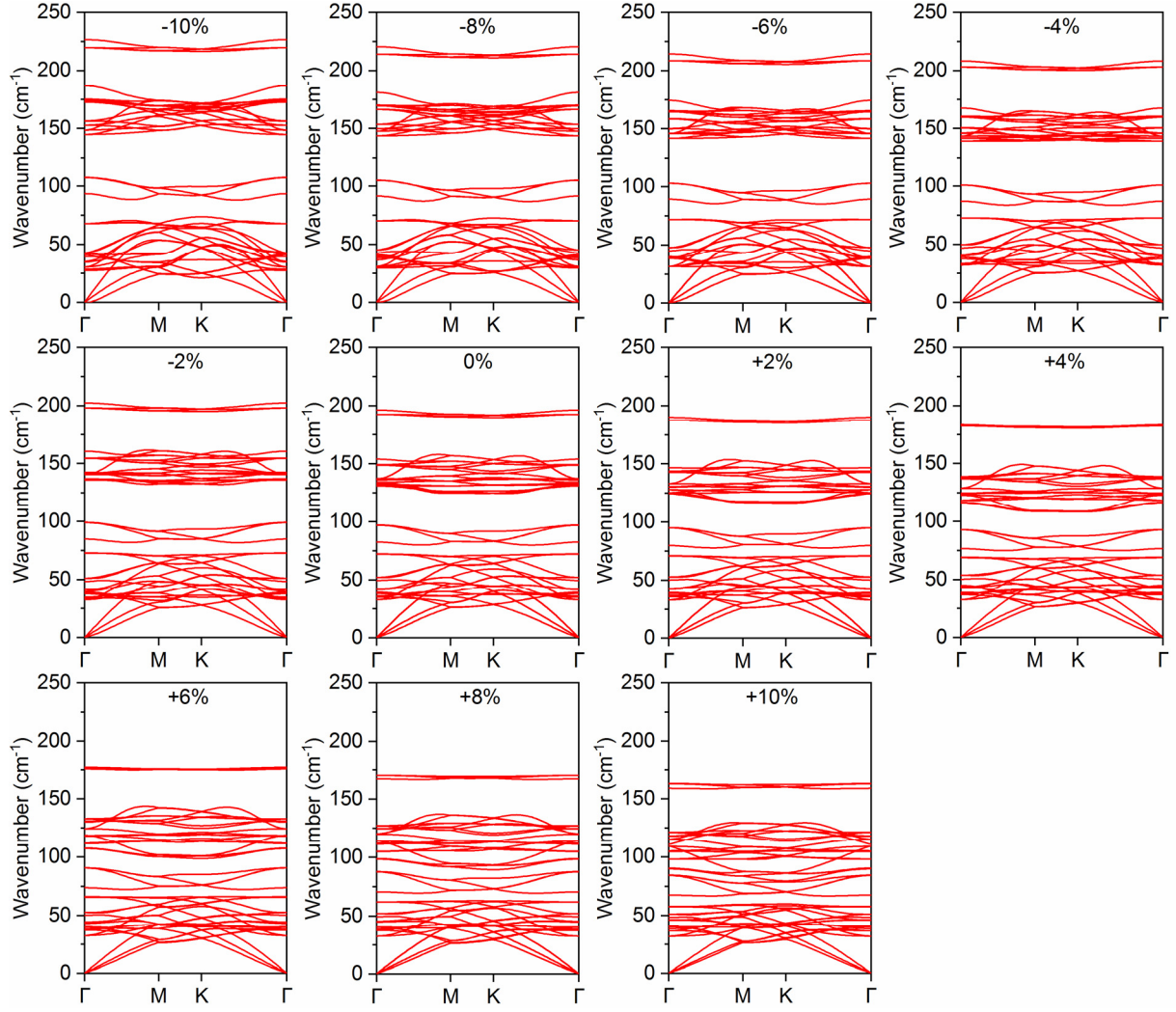


Figure S4. Phonon dispersions for InTe monolayer under biaxial lattice strain from -10% to +10%. Absence of imaginary phonon vibration modes confirms the dynamical stability of 2D InTe under biaxial strain from -10% to +10%.

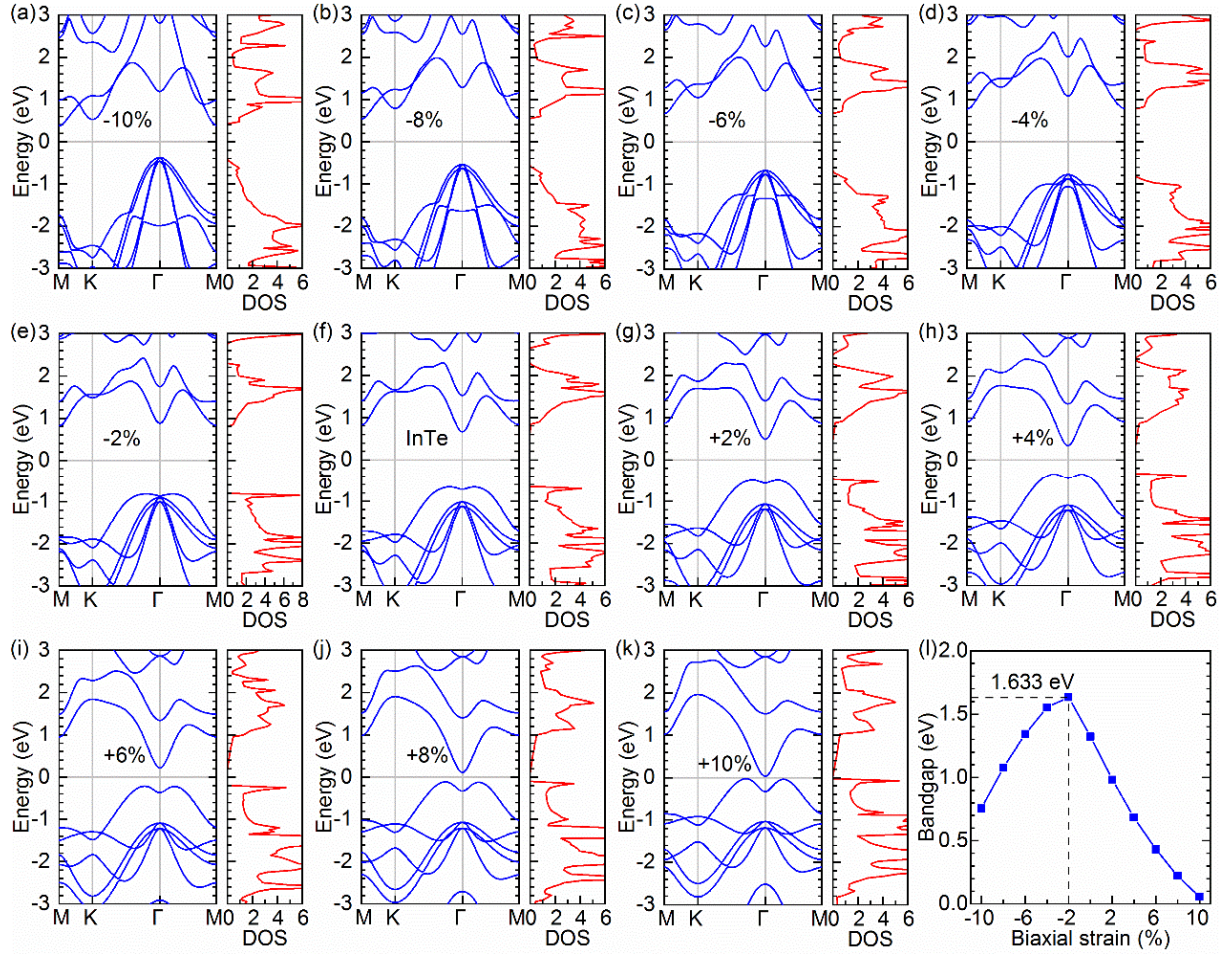


Figure S5. (a-k) Electronic band structures and density of states (DOS) and (l) electronic band gap for InTe monolayer under biaxial lattice strain from -10% to +10%. InTe monolayer has the largest bandgap of 1.633 eV under -2% compressive strain.